

Characteristics of Valley Microstrip Lines for Use in Multilayer MMIC's

T. Hasegawa, S. Banba, H. Ogawa and H. Nakamoto. "Characteristics of Valley Microstrip Lines for Use in Multilayer MMIC's." 1991 Microwave and Guided Wave Letters 1.10 (Oct. 1991 [MGWL]): 275-277.

A valley microstrip line fabricated by using multilayer MMIC technologies is proposed and its performance is investigated experimentally. Insertion loss of the valley microstrip line is smaller than that of conventional microstrip lines having the same width of strip conductor.

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